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## Electronic Supplementary Information

### Synthesis and Characterization of a Hierarchically Structured Three-Dimensional Conducting Scaffold for Highly Stable Li Metal Anodes

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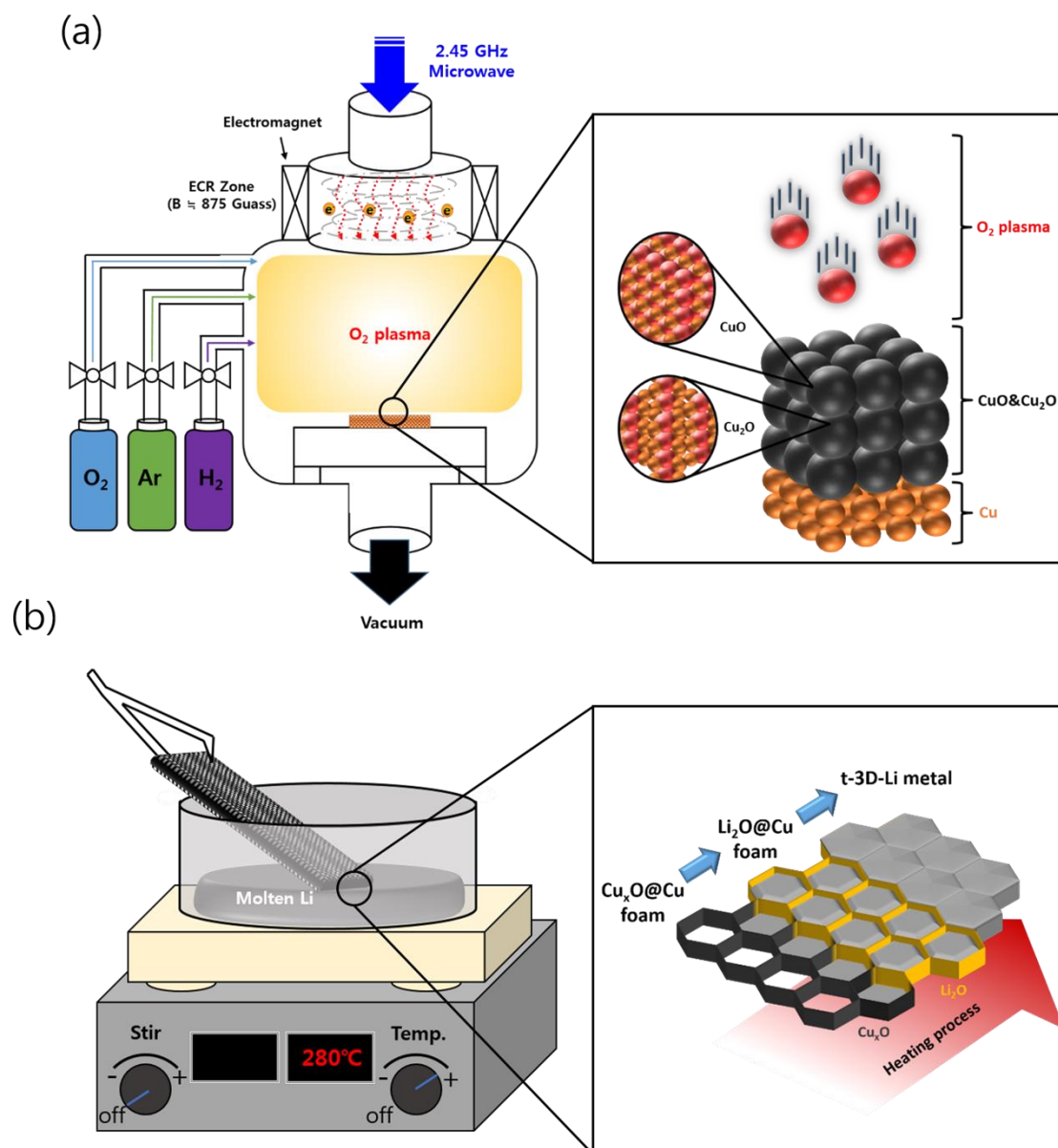
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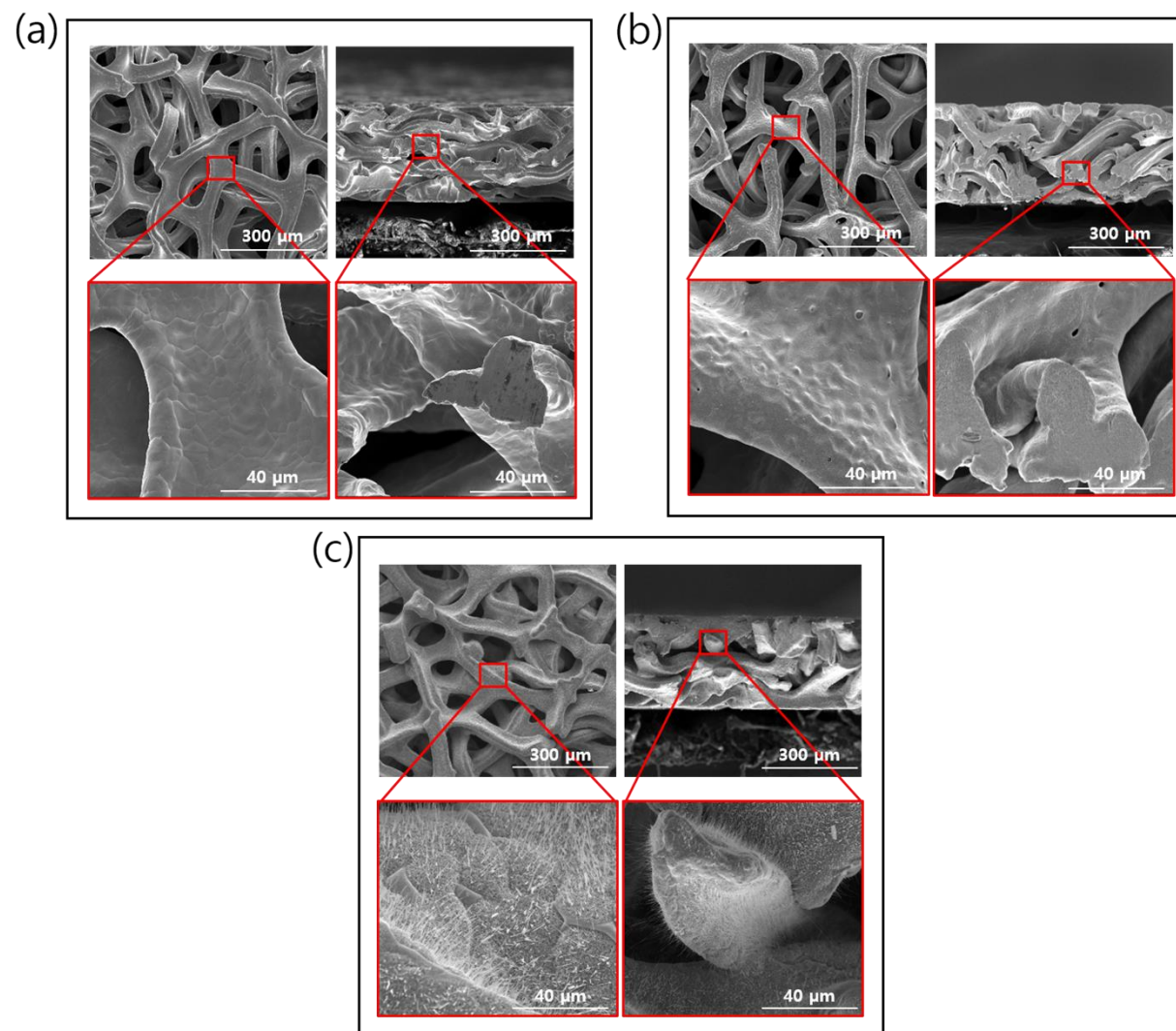
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This file contains Supplementary Figures S1-S12 and Tables S1-S6.

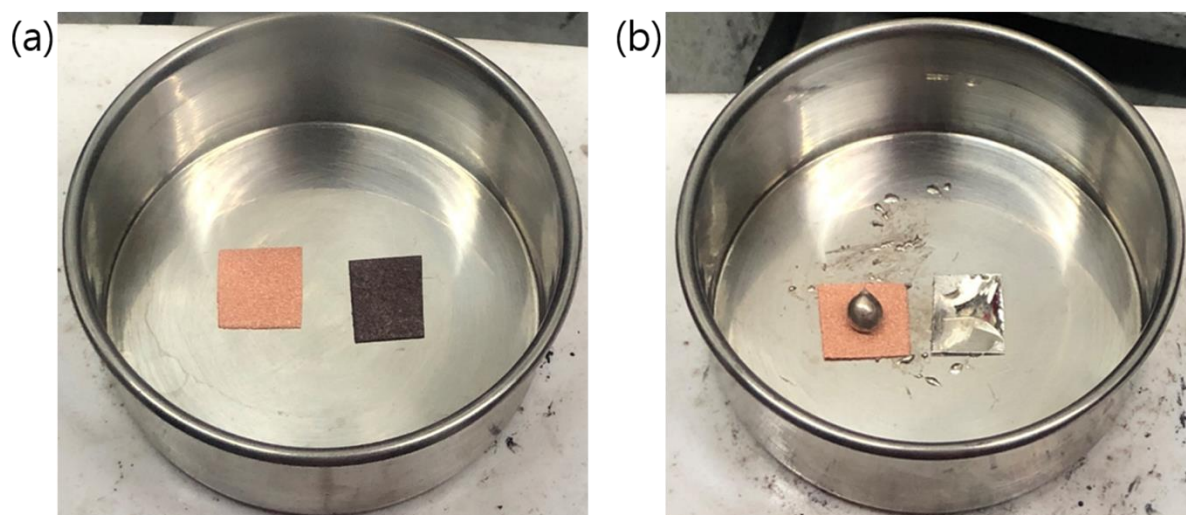
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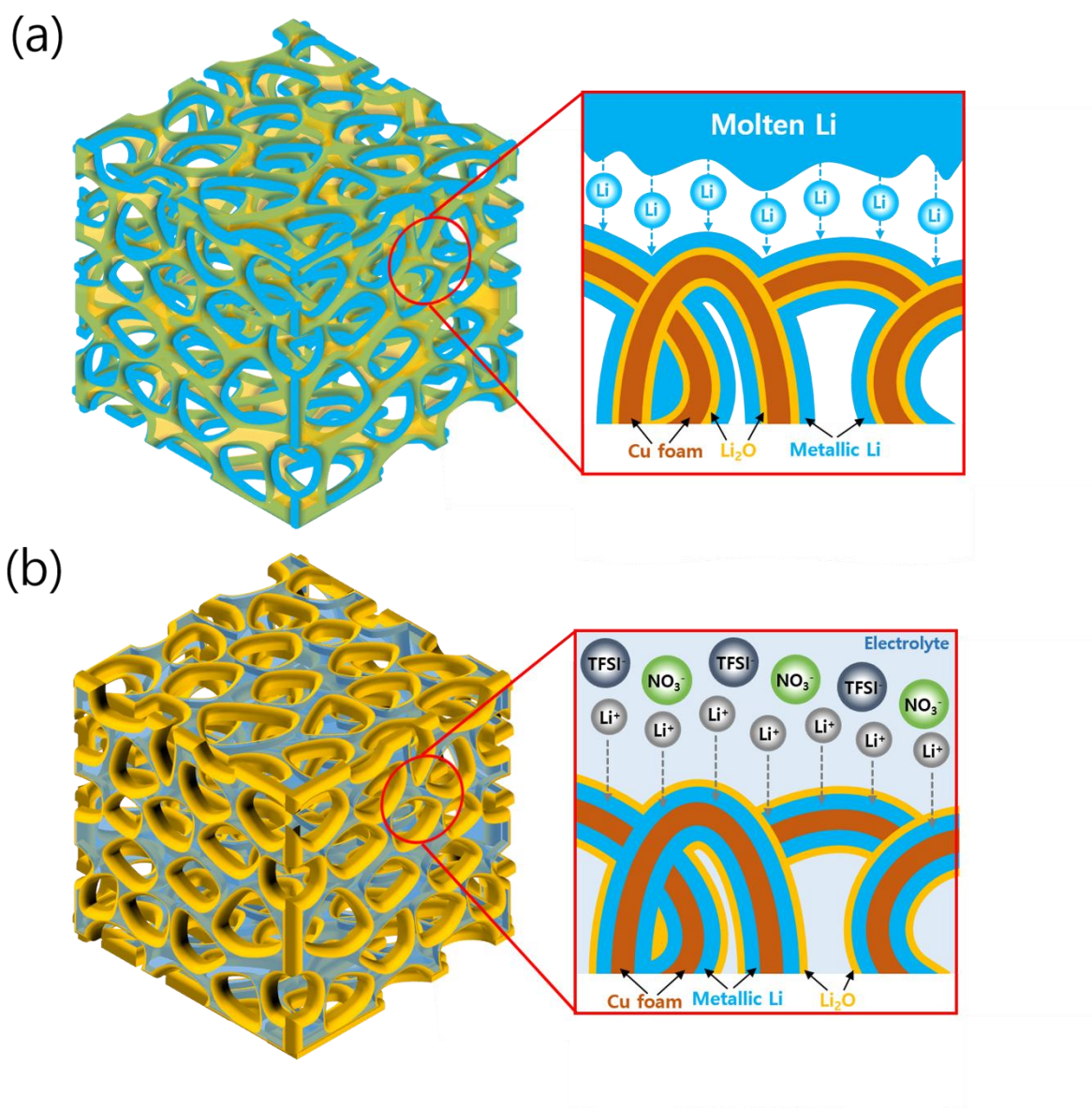
**Figure S1.** Schematic illustration of (a) ECR plasma oxidation used to prepare  $Cu_xO@Cu$  foam and (b) the fabrication of the t-3D-Li metal electrode.



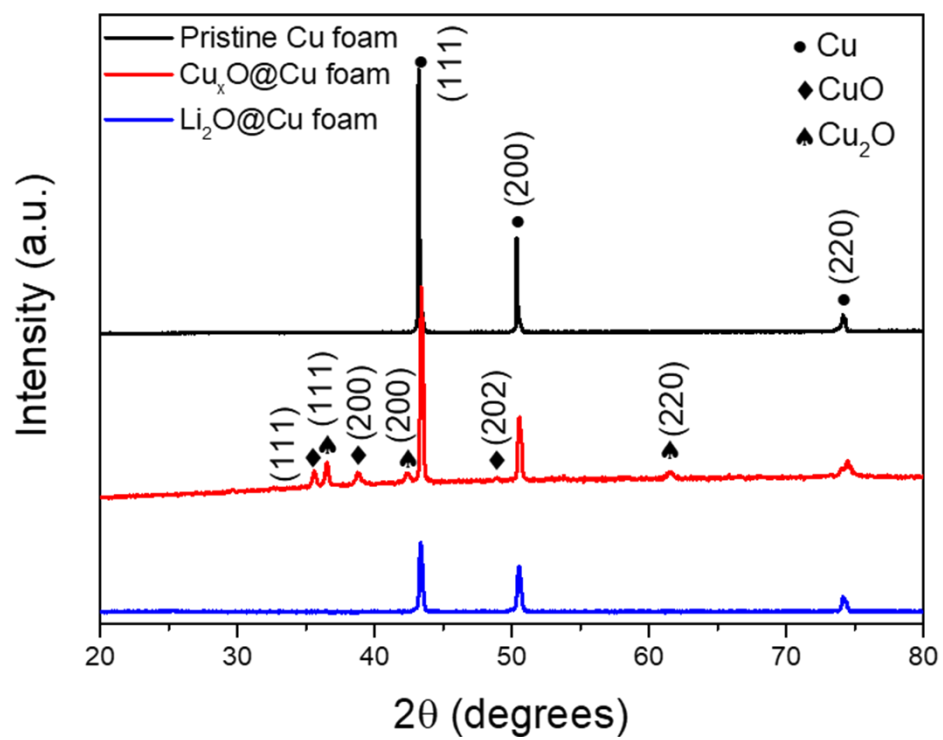
**Figure S2.** Top-view and cross-sectional images of Cu foam subjected to different surface treatments: (a) pristine Cu foam;  $\text{Cu}_x\text{O}@Cu$  foam prepared by (b) ECR  $\text{O}_2$  plasma treatment and (c) heat treatment.



**Figure S3.** Photographs of Cu foam and  $\text{Cu}_x\text{O}@\text{Cu}$  foam (a) before and (b) after Li impregnation at 280 °C.

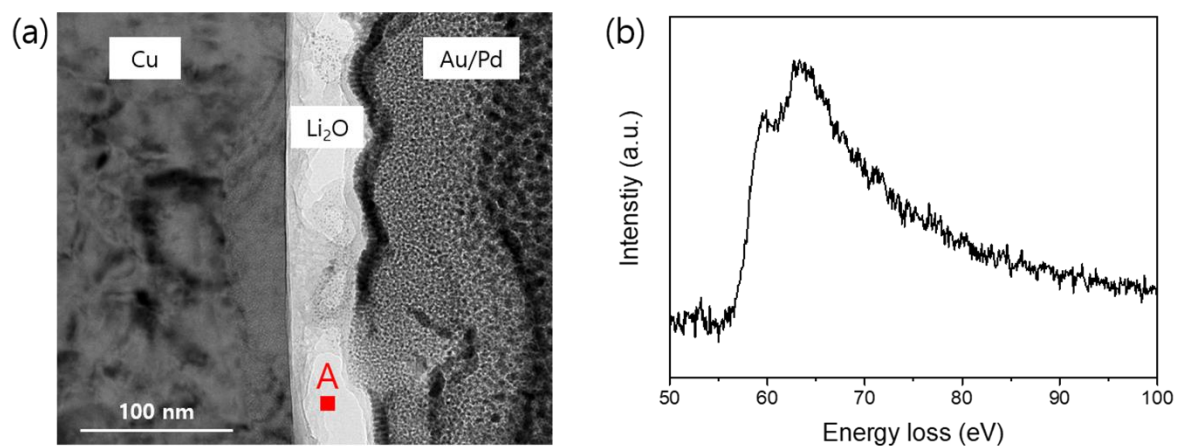


**Figure S4.** Detailed hierarchical structures of (a) t-3D-Li metal and (b) e-3D-Li metal anodes.

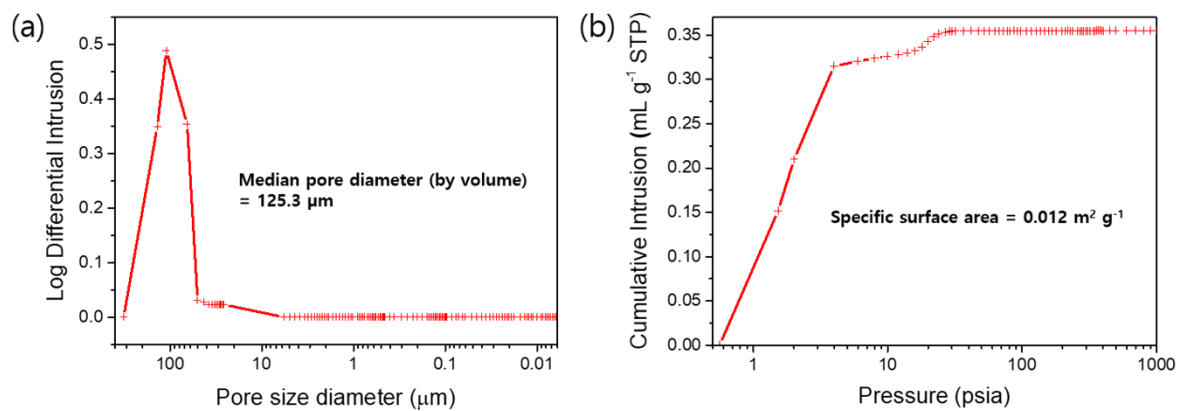


**Figure S5.** XRD patterns of pristine Cu foam,  $\text{Cu}_x\text{O}@Cu$  foam, and  $\text{Li}_2\text{O}@Cu$  foam.



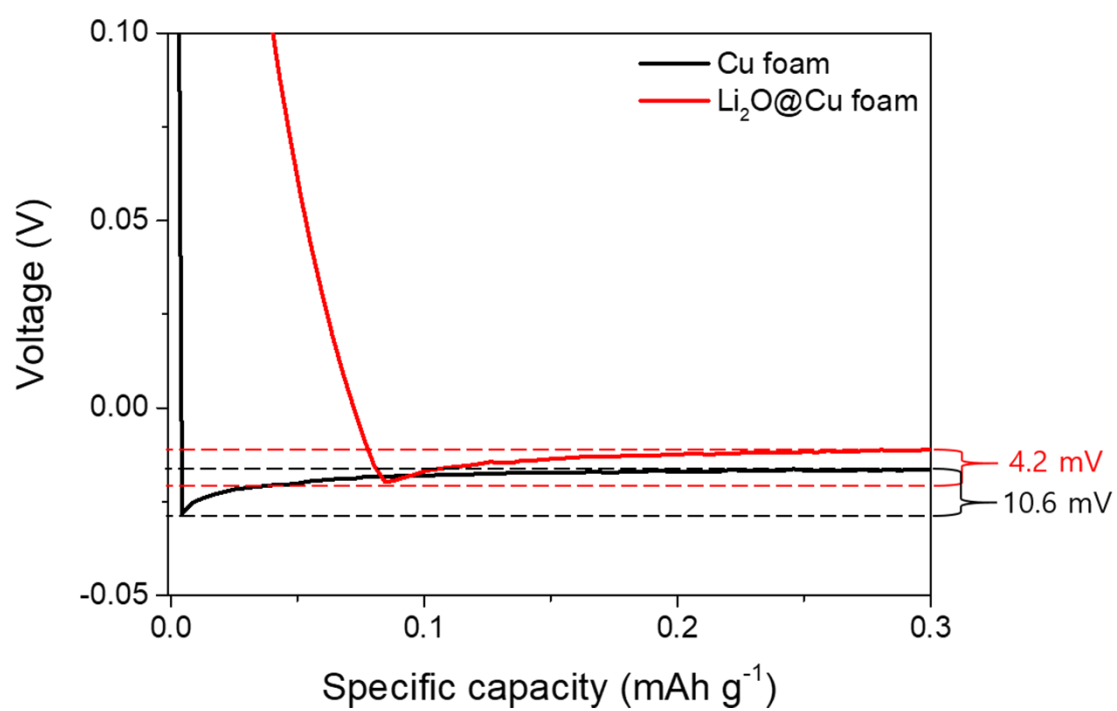


**Figure S6.** (a) HAADF-STEM images of Li<sub>2</sub>O@Cu and (b) EELS analysis of the Li-K edge. (Note: The specimen was sputter-coated with Au/Pd to avoid damage and surface charge under the Ga<sup>+</sup> ion beam.)

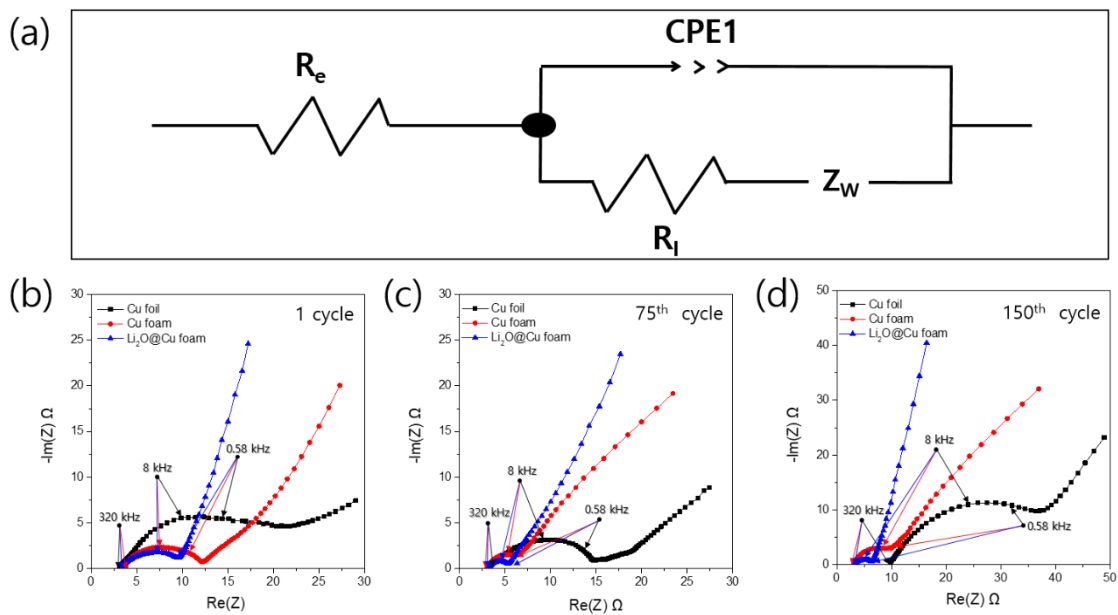


**Figure S7.** (a) Pore size distribution and (b) intrusion curve of Cu foam determined by Hg porosimetry.

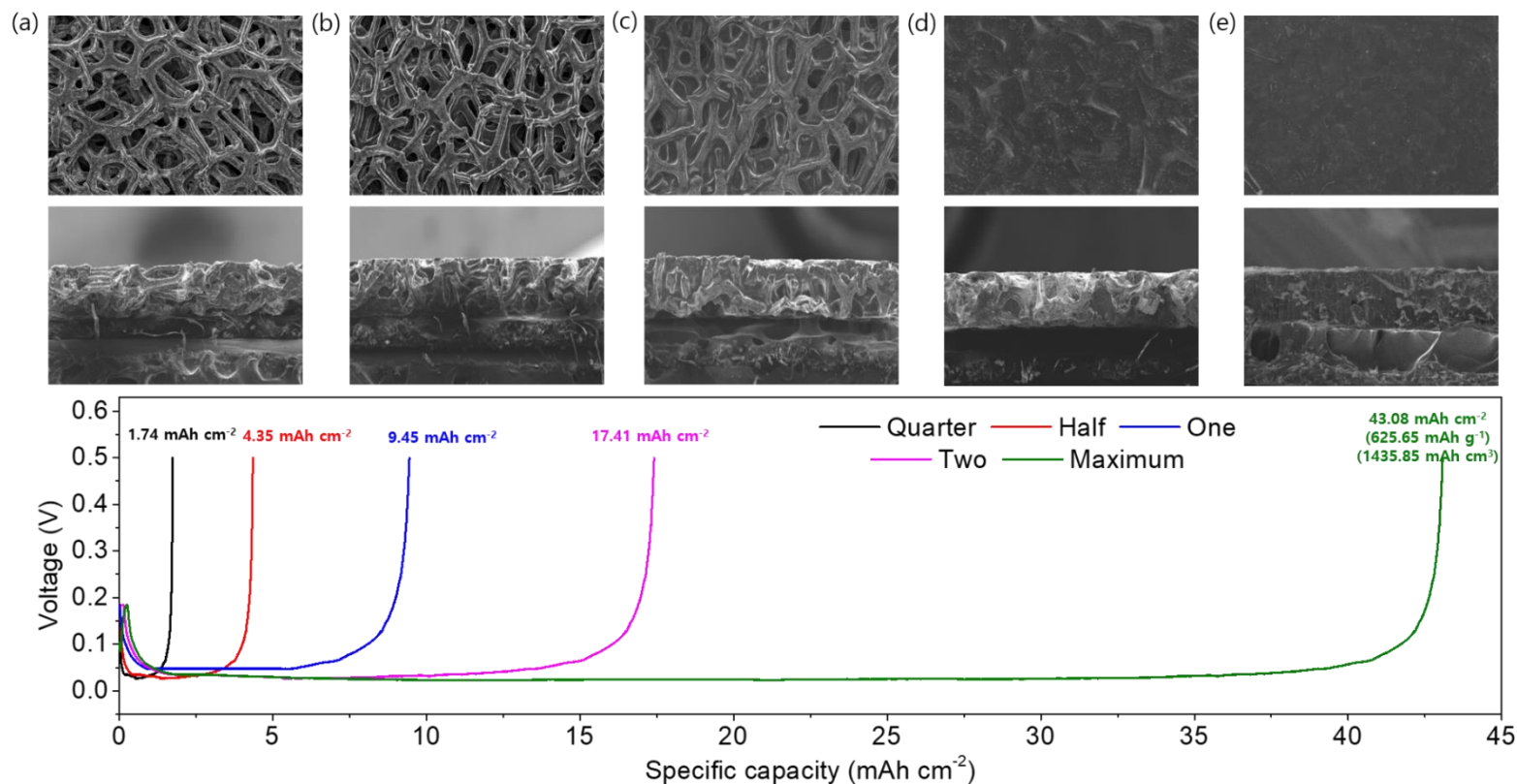




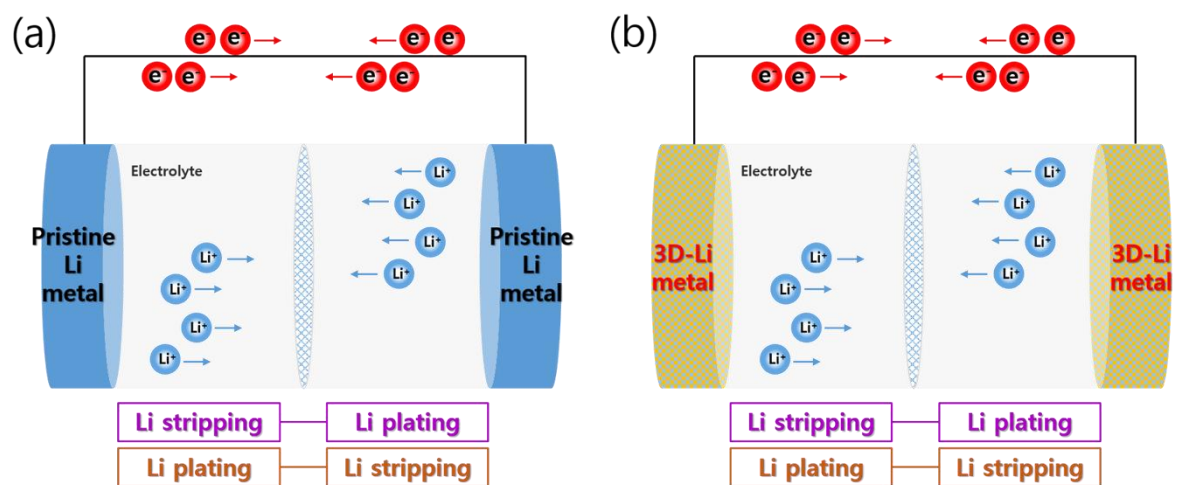
**Figure S8.** Voltage profiles of Cu foam and Li<sub>2</sub>O@Cu foam recorded at a current density of 0.5 mA cm<sup>-2</sup>.



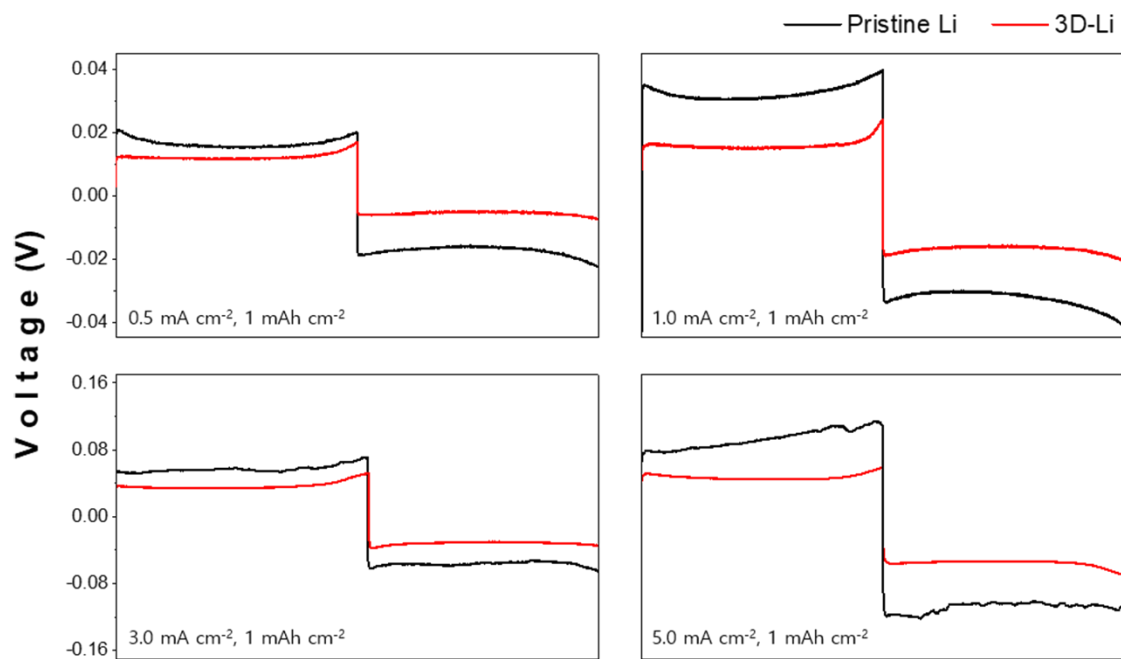
**Figure S9.** (a) Equivalent circuit curve for Nyquist plots of Li/Cu cells. (b, c, d) The corresponding Nyquist plots with frequency information at different cycle.



**Figure S10.** Top-view and cross-sectional images of t-3D-Li metal electrodes with different amounts of impregnated molten Li (measured in multiples/fractions of one bare Li foil with a diameter of 12 mm (0.03 g)). Images of Li<sub>2</sub>O@Cu foam impregnated using (a) one quarter, (b) one half, (c) one, (d) two Li foils and (e) excess Li. The Cu<sub>x</sub>O@Cu foam sample had a width and length of 2 cm and a thickness of 300  $\mu$ m. The cutoff voltage was set at 0.5 V. (Note: The gravimetric and volumetric capacity calculated by total weight and volume of t-3D-Li metal including the Cu foam exhibit specific capacities of 625.65 mAh g<sup>-1</sup> and 1,435.85 mAh cm<sup>-3</sup>, respectively, shown in the green curve. Comparing theoretical capacity of pristine Li metal (2,061 mAh cm<sup>-3</sup>) with the volumetric capacity of the excessive Li impregnated t-3D-Li metal (1,435.85 mAh cm<sup>-3</sup>), we can know that the porosity of the Cu foam is 69.6%. As a standard areal capacity for electrochemical test, The areal capacity of 1.0 mAh cm<sup>-2</sup> is corresponding to volumetric capacity of 33.33 mAh cm<sup>-3</sup> owing to the thickness of Cu foam (here, i.e. 300  $\mu$ m). Therefore, the volumetric capacity of 33.33 mAh cm<sup>-3</sup> matches with pore occupation of 2.32% of the t-3D-Li metal.)



**Figure S11.** Configuration of the symmetric cell with (a) pristine Li and (b) 3D-Li metal for galvanostatic cycling.



**Figure S12.** Expanded voltage profiles (corresponding to blue dashed rectangles in Fig. 7) of symmetric cells comprising pristine Li and 3D-Li metal electrodes.

**Table S1.** Inherent coefficients of each materials for Shomate equation.

(550K)	Cu	Li <sub>2</sub> O	Cu <sub>2</sub> O	CuO	Molten Li
A	17.72891	68.6971	59.42033	48.56494	32.46972
B	28.0987	5.467149	37.84767	7.498607	-2.635975
C	-31.25289	23.18308	-26.45083	-0.05598	-6.327128
D	13.97243	-9.495631	11.07609	0.013851	4.230359
E	0.068611	-1.60244	-0.54218	-0.760082	0.005686
F	-6.056591	-625.0352	-191.7109	-173.4272	-7.117319
G	47.89592	109.3928	151.0177	94.85128	74.29361
H	0	-598.7304	-170.7072	-156.0632	2.380002

**Table S2.** Thermodynamic parameters of each materials calculated by Shomate equation.

	Enthalpy	Entropy	Gibbs free energy
	(H, kJ/mol)	(S, J/mol·K)	(G <sub>550K</sub> , kJ/mol)
Cu	6.4059	48.9125	-20.4960
Li <sub>2</sub> O	-544.4125	71.6612	-583.8268
O <sub>2</sub>	7.6507	223.6550	-115.3596
Cu <sub>2</sub> O	-151.4258	132.0277	-224.0410
CuO	-145.4399	68.6776	-183.2126
Liquid Li	7.6979	52.7193	-21.2977

**Table S3.** The determination of the spontaneity of the three kinds of chemical reactions based on difference of difference of Gibbs free energy.

	Formula	$\Delta G_{\text{Rxn}} = \sum G_{550\text{K}}(\text{products}) - \sum G_{550\text{K}}(\text{reactants})$	Value of $\Delta G_{\text{Rxn}}$
Rxn ①	$\text{CuO} + 2\text{Liquid Li} \rightarrow \text{Cu} + \text{Li}_2\text{O}$	$\Delta G_{\text{Rxn}} = [\text{G}(\text{Cu}) + \text{G}(\text{Li}_2\text{O})] - [\text{G}(\text{CuO}) + 2\text{G}(\text{Liquid Li})]$	-378.5141
Rxn ②	$\text{Cu}_2\text{O} + 2\text{Liquid Li} \rightarrow 2\text{Cu} + \text{Li}_2\text{O}$	$\Delta G_{\text{Rxn}} = [2\text{G}(\text{Cu}) + \text{G}(\text{Li}_2\text{O})] - [\text{G}(\text{Cu}_2\text{O}) + 2\text{G}(\text{Liquid Li})]$	-358.1817

The spontaneity of a chemical reaction can be generally determined from the corresponding change of Gibbs free energy. In turn, Gibbs free energy is defined as  $H(T) - T \times S(T)$ , where  $H$  is enthalpy,  $T$  is absolute temperature, and  $S$  is entropy. The second law of thermodynamics implies that spontaneous phenomena are characterized by an increase of overall entropy ( $\Delta S > 0$ ), i.e., spontaneous reaction should feature negative changes of Gibbs free energy ( $\Delta G < 0$ ). To determine the Gibbs free energy of a certain material, one needs to know the corresponding enthalpy and entropy, which were herein calculated using the Shomate equation:<sup>[1]</sup>

$$\textcircled{1} \quad \text{Enthalpy } (H, \text{ kJ mol}^{-1}): H_{298.15}^{\circ} + A * t + \frac{Bt^2}{2} + \frac{Ct^3}{3} + \frac{Dt^4}{4} - \frac{E}{t} + F - H,$$

$$\textcircled{2} \quad \text{Entropy } (S, \text{ J mol}^{-1} \text{ K}^{-1}): A * \ln t + Bt + \frac{Ct^2}{2} + \frac{Ct^3}{3} + \frac{E}{2t^2} + G,$$

where  $t$  is temperature (K) divided by 1000, the shomate parameters are listed in Table S1 using a symbol of  $A$ ,  $B$ ,  $C$ ,  $D$ ,  $E$ ,  $F$ ,  $G$  and  $H$ . The calculated thermodynamic parameters are listed in Table S2. The  $\Delta G$  values under our experimental conditions ( $T = 550 \text{ K}$ ) were determined from the standard Gibbs free energies of each material. As shown in Table S3,  $\Delta G$  for a chemical reaction was defined as the difference between the sum of Gibbs free energies of all products and that of all reactants. Both the reduction of  $\text{Cu}_x\text{O}$  ( $x = 1, 2$ ) and the oxidation of molten Li were characterized by negative  $\Delta G$  values and were therefore spontaneous.



**Table S4.** Electrochemical impedances simulated from equivalent circuit curve of Cu foil, Cu foam and Li<sub>2</sub>O@Cu foam.

	Cu foil		Cu foam		Li <sub>2</sub> O@Cu foam	
	R <sub>e</sub>	R <sub>i</sub>	R <sub>e</sub>	R <sub>i</sub>	R <sub>e</sub>	R <sub>i</sub>
1 <sup>st</sup>	3.077	17.983	3.214	6.439	3.232	7.326
75 <sup>th</sup>	3.328	11.17	3.183	3.295	3.016	2.272
150 <sup>th</sup>	19.14	21.6	3.200	5.364	3.044	2.878

**Table S5.** The specific values of Coulombic efficiency for each Cu substrates at higher current density of 1.0, 3.0 and 5.0 mA cm<sup>-2</sup>.

Cycle	1 <sup>st</sup>	10 <sup>th</sup>	20 <sup>th</sup>	30 <sup>th</sup>	40 <sup>th</sup>	50 <sup>th</sup>	60 <sup>th</sup>	70 <sup>th</sup>	80 <sup>th</sup>	90 <sup>th</sup>	100 <sup>th</sup>
1.0 mA/cm <sup>2</sup>	Cu foil	91.7 %	90.6 %	92.0 %	89.3 %	77.3 %	-	-	-	-	-
	Cu foam	94.0 %	97.4 %	98.7 %	98.3 %	98.8 %	98.6 %	98.4 %	96.8 %	81.5 %	-
	Li <sub>2</sub> O	94.0 %	98.3%	99.4 %	99.6 %	99.3 %	99.1 %	99.2 %	99.2 %	99.0 %	98.8 %
	@Cu foam										99.0%
Cycle	1 <sup>st</sup>	10 <sup>th</sup>	20 <sup>th</sup>	30 <sup>th</sup>	40 <sup>th</sup>	50 <sup>th</sup>	60 <sup>th</sup>	70 <sup>th</sup>	80 <sup>th</sup>	90 <sup>th</sup>	100 <sup>th</sup>
3.0 mA/cm <sup>2</sup>	Cu foil	86.8 %	83.7 %	84.3 %	84.4 %	81.3 %	73.5 %	-	-	-	-
	Cu foam	84.1 %	96.6 %	97.3 %	97.4 %	97.4 %	96.9 %	93.2 %	86.9 %	77.1 %	-
	Li <sub>2</sub> O	88.4 %	96.0%	98.2 %	97.5 %	97.5 %	98.2 %	97.5 %	97.0 %	96.6 %	97.5 %
	@Cu foam										97.5%
Cycle	1 <sup>st</sup>	10 <sup>th</sup>	20 <sup>th</sup>	30 <sup>th</sup>	40 <sup>th</sup>	50 <sup>th</sup>	60 <sup>th</sup>	70 <sup>th</sup>	80 <sup>th</sup>	90 <sup>th</sup>	100 <sup>th</sup>
5.0 mA/cm <sup>2</sup>	Cu foil	85.9 %	80.4 %	85.7 %	92.7 %	92.0 %	77.4 %	-	-	-	-
	Cu foam	85.0 %	96.8 %	93.3 %	89.3 %	91.3 %	96.3 %	96.9 %	94.9 %	84.4 %	-
	Li <sub>2</sub> O	87.1 %	96.2 %	98.0 %	96.8 %	96.0 %	96.7 %	97.2 %	97.4 %	95.7 %	97.5 %
	@Cu foam										97.5%

**Table S6.** The comparison of Coulombic efficiency of porous current collector for Li metal anode with previous literatures

Porous scaffold	Lithiophilic agent	Current density (mA cm <sup>-2</sup> )	Capacity (mAh cm <sup>-2</sup> )	CE	Cycle	Reference
		0.5		99.0 %	150	
Cu foam	Li <sub>2</sub> O	1.0	1.0	99.0 %	100	This work
		3.0		97.5 %	100	
		5.0		97.5 %	100	
Cu foam	- (Mechanical pressing)	0.5	1.0	93.8 %	100	[2]
Porous Cu foil	X (Not Li impregnated)	0.5	1.0	98.5 %	50	[3]
Porous Cu foil	X (Not Li impregnated)	0.5	1.0	97.0 %	250	[4]
		1.0			140	
Graphene flake	X (Not Li impregnated)	0.5	0.5	93.0 %	50	[5]
		2.0	1.0	90.0 %		
Cu nanowire film	X (Not Li impregnated)	1.0	2.0	98.6 %	200	[6]
Cu-CuO-Ni hybrid structure	CuO	3.0	0.5	90.0 %	100	[7]
Ni foam	- (Mechanical pressing)	1.0	1.0	85.0 %	100	[8]
Graphene@Ni foam	X (Not Li impregnated)	0.5	1.0	98.0 %	100	[9]
		1.0		92.0 %		
CuO nanosheets on Cu foil	CuO	0.5				[10]
		1.0	1.0	94.0 %	180	

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